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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

**INFORMATION DISCLOSURE STATEMENT** 

**APPLICANTS:** 

Sven-Erik HEDBERG et al

**CONFIRMATION NO.: 4870** 

**SERIAL NO.:** 

10/720,449

**GROUP ART UNIT: 3762** 

FILED:

November 24, 2003

TITLE:

"IMPLANTABLE BI-VENTRICULAR STIMULATION DEVICE AND SYSTEM, AND BI-VENTRICULAR STIMULATION AND SENSING

METHOD

MAIL STOP AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

SIR:

In accordance with the provisions of 37 C.F.R. § 1.56, Applicants request that citation and examination of the following documents be made during the course of examination of the above-referenced application for United States Letters Patent.

AA United States Patent No. 6,370,430

AB United States Patent No. 6,070,100

AC United States Patent No. 5,720,768

AD U. S. Patent Application Publication 2002/0082650

AL European Application 1 123 716

AU "Inhibition of Biventricular Pacing by Far-Field Left Atrial Activity Sensing: Case Report," Oguz, PACE, Vol. 25, No. 10 (October 2002) pages 1517-1519.

## **EXPLANATION OF RELEVANCE**

References AB and AC were identified and discussed in the present specification, and Applicants stand by the statements in the specification concerning the teachings of these references.

References AA, AD, AL and AU were cited in a Search Report rendered by the Swedish Patent Office during examination of the counterpart Swedish application. A copy of the Swedish Search Report is submitted herewith. All of these references were cited in Category "A" as general technological background information.

Copies of each of the above References together with Form 1449 are submitted herewith.

As of the date of mailing of this Information Disclosure Statement, a first Office Action on the merits has not been received in connection with this application. This Information Disclosure Statement is therefore in compliance with 37 C.F.R. §1.97(b)(3), and no fee is necessary.

All claims of the application are submitted to be patentable over the teachings of the above references, taken singly or in combination. Early consideration of the application is therefore respectfully requested.

Submitted by,

SCHIFF, HARDIN LLP

**CUSTOMER NO. 26574** 

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## **CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450 on September 20, 2004.

Sheet 1 of 1

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Form PTO-1449 INFORMATION DISCLOSURE CITATION					Docke			Serial No.	
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	AA	6,370,430	04/09/02	Mika et al.			T		
	AB	6,070,100	05/30/00	Bakels et al.					
	AC	5,720,768	02/24/98	Verboven-Nelissen					
	AD	2002/0082650	06/27/02	Stahmann et al.					
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.